

7th IEEE Electron Devices Technology and Manufacturing (EDTM) Conference 2023

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47F. Memory for New Applications	
Session Date:	March 9(Thu.), 2023
Session Time:	16:30-18:00
Session Room:	Room F (#317)
Session Chair:	Prof. Tae-Sik Yoon (Ulsan National Institute of Science and Technology)
	Prof. Kyung Min Kim (Korea Advanced Institute of Science and Technology)
[47F-1]	16:30-16:45

[47F-1]

Demonstration of Ultra-Thin Ferroelectric/Dielectric and Anti-Ferroelectric/Dielectric Bilayers for Future **DRAM Cell Capacitors**

Dong Ik Suh, Won-Tae Koo, Youngmo Kim, Ja-Yong Kim, Seung Wook Ryu, Heeyoung Jeon, Ki Vin Im, Gwangyeob Lee, Taeone Youn, Hyeonho Jeong, Seho Lee, Myung-Hee Na and Seon Yong Cha SK hynix Inc.

[47F-2]

A Ferroelectric Differential Bit Cell Based Multiple-Time Programmable Physical Unclonable Function (PUF) for IoT Devices Security

Paritosh Meihar, Srinu Rowtu, Sandip Lashkare and Udayan Ganguly

Indian Institute of Technology Bombay

[47F-3]

A Novel Pulse-Width-Modulated FeFET-Based Analog Content Addressable Memory with High Area-And Energy-Efficiency

Weikai Xu¹, Jin Luo¹, Qianqian Huang^{1,2,3} and Ru Huang^{1,2,3}

¹Peking University, ²Beijing Advanced Innovation Center for Integrated Circuits, ³Chinese Institute for Brain Research

[47F-4]

Novel Complementary FeFET- Based Lookup Table and Routing Switch Design and Their Application in **Energy/Area-Efficient FPGA**

Yuan-Yu Huang, Po-Tsang Huang, Po-Yi Lee and Pin Su

National Yang Ming Chiao Tung University

[47F-5]

A 40-nm Embedded 1T-OTP MACRO with Gate-Oxide-Charge Storage by Channel-Hot-Electron-Injection Featuring 0.086 µm²/cell, 1.8 V of Program-Voltage, 125 °C Retention

Y. H. Ye, Y. X. Huang, H. S. Su, R. Q. Lin, Y.-H. Lin, K. H. Chang, T. H. Shen and E Ray Hsieh National Central University

[47F-6]

Self-Clocking Fast and Variation Tolerant True Random Number Generator Based on a Stochastic Mott Memristor

Gwangmin Kim, Jae Hyun In, Young Seok Kim, Hakseung Rhee, Woojoon Park, Hanchan Song, Juseong Park and Kyung Min Kim

Korea Advanced Institute of Science and Technology

17:45-18:00

16:45-17:00

17:00-17:15

17:15-17:30

17:30-17:45